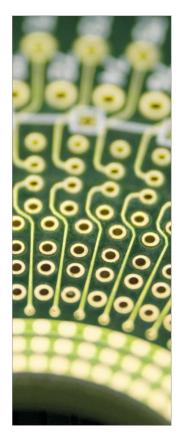


## **Umicore** Electroplating

# ENEPIG PROCESS

### ELECTROLESS NICKEL ELECTROLESS PALLADIUM AND IMMERSION GOLD PLATING



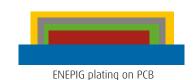
#### Electroless Palladium, Electroless Nickel and Semi-Autocatalytic Gold Plating

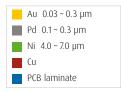
Umicore's ENEPIG process provides an universal finish to the PCB industry with excellent wire-bonding performance and the highest degree of solder joint reliability (SJR) with lead-free SAC 305 alloy. The palladium slows the diffusion of tin into the nickel resulting in a minimum thickening of the nickeljtin IMC (= intermetallic compound), even following thermal stress of 1000 hours at 150  $^{\circ}$ c.

The possible use of unique semi-autocatalytic gold electrolyte Gobright® TWX-40 also enables to deposit even thicker gold layers with very uniform thickness distribution depending on customer requirements. The combination of electroless processes (nickel and palladium) and the final gold plating with this special type of electrolyte ensures a corrosion-free final finish system for highend applications and mixed assembly processes on same surface.

Moreover ENEPIG films are less expensive in comparison to electrolytic or electroless bondable gold like ENAG (= Electroless nickel + Autocatalytic gold) and additionally comply with latest RoHs and WEEE regulations.

## ENEPIG as Final Finish







#### Advantages

- Universal finish for soldering and wire-bonding applications
- + Highly robust solder joints with SAC solder
- Excellent contact surface
- Electroless process
- · Less expensive than electrolytical gold finishes
- Dense and homogenous gold protection layer from 0.03 0.3  $\mu m$

#### Applications

- IC package PCB substrate
- Multi-functional assembly
- PCB for harsh environment

## ENEPIG PROCESS

## ELECTROLESS NICKEL ELECTROLESS PALLADIUM AND IMMERSION GOLD PLATING

## **TECHNICAL SPECIFICATIONS ELECTROLESS NICKEL PLATING**

| Electrolyte characteristics | s Nimuden® NPR-8-2    |           |
|-----------------------------|-----------------------|-----------|
| Electrolyte type            | Autocatalytic process | Coating o |
| pH value and temperature    | 4.6 at 84 ° c         | Recomm    |
| Deposition rate             | 12 µm / h             |           |

| Coating characteristics |                   |  |
|-------------------------|-------------------|--|
| Coating composition     | Nickel-Phosphorus |  |
| Recommended thickness   | 4.0 - 7.0 μm      |  |
|                         |                   |  |

characteristics

Palladium-Phosphorus

0.1 - 0.3 µm

### **TECHNICAL SPECIFICATIONS ELECTROLESS PALLADIUM PLATING**

| Electrolyte charac    | teristics XTP (MW)       | Coat                |
|-----------------------|--------------------------|---------------------|
| Electrolyte type      | Autocatalytic process    | Coating composition |
| Metal content         | 0.6 (0.45 - 0.75) g/l Pd | Recommended thickne |
| pH value              | 7.2 (7.0-7.5)            |                     |
| Operating temperature | 50 °C                    |                     |
| Deposition rate       | 0.1 µm / 10 min          |                     |

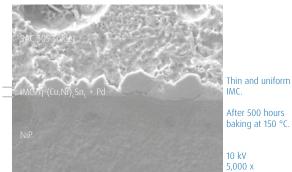
## TECHNICAL SPECIFICATIONS (SEMI AUTOCATALYTIC) GOLD PLATING

| Electrolyte characteristics Gobright® TWX-40 |                         |  |
|--|-------------------------|--|
| Electrolyte type                             | Semi autocatalytic      |  |
| Metal content                                | 1.2 (1.0 - 1.4) g/l Au  |  |
| pH value                                     | 7.1 (6.9 - 7.4)         |  |
| Operating temperature                        | 78 (76 - 84) °C         |  |
| Deposition rate                              | 0.12 µm/15 min at 78 °C |  |

| Coating characteristics |               |
|-------------------------|---------------|
| Coating composition     | Fine gold     |
| Purity                  | 99.9 wt %     |
| Recommended thickness   | 0.03 - 0.1 µm |

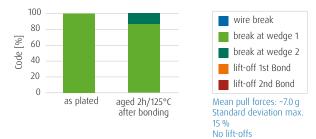
## ENEPIG PROCESS ELECTROLESS NICKEL ELECTROLESS PALLADIUM AND IMMERSION GOLD PLATING

#### Cross-Section Observation by SEM of ENEPIG Solder Joint

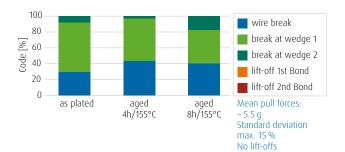


After 500 hours baking at 150 °C

#### Aluminium Wire Pull Test Results, AlSi1 25 µm

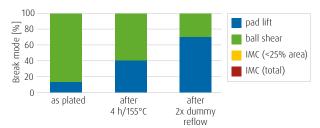


#### Gold Wire Pull Test Results, Heraeus HD2 25 µm



#### **BGA Solder Ball Shear Results**

(ball size 0.76 mm, SAC solder, 4.8 µm NiP, 0.15 µm Pd, 0.06 µm Au)



#### **YOUR CONTACT**

Do you have a specific question or would you like a no-obligation quote calculation? Our specialist will be happy to help you with any technical questions you might have.



Markus Legeler

Mail:

Manager Sales International

markus.legeler@eu.umicore.com Phone: +49 (0) 7171 607 - 204



The information and statements contained herein are based on our experience in the fields of research and applied technology and are believed to be accurate at the time of publication, but - unless agreed in writing - we make no warranty with respect thereto, including but not limited to any results to be obtained. This product information sheet in the English language prevails any translation.

www.ep.umicore.com